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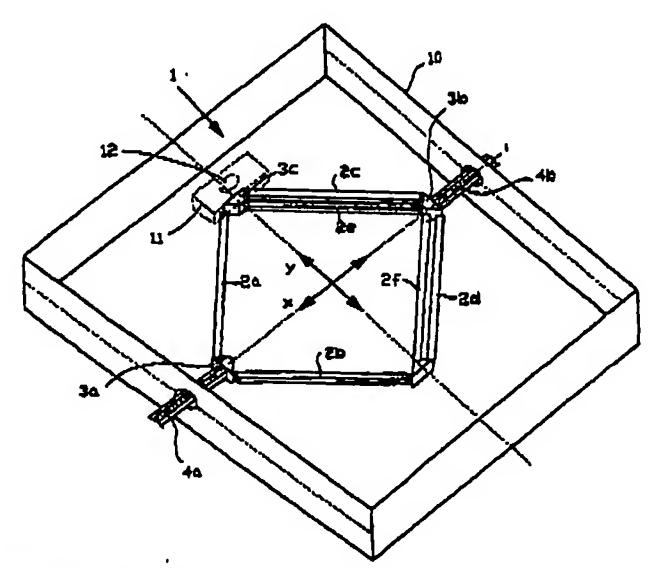
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(54) Title: STAGE DEVICE FOR A VACUUM CHAMBER



(57) Abstract: The invention relates to a transfer stage for moving an object in a vacuum chamber in at least a plane of movement, comprising at least a first and a second rod each having a first and a second end, the first and second rod being connected one to the other with their first ands by means of a first hinge, the second end of the first rod being provided with a first hinged support and the second end of the second rod being provided with a second hinged support, the first and second hinged supports being roller supports and the first hinge being provided with attachment means for the object. Particularly when using this transfer stage in lithography systems fast and reliable movements are possible.

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